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Authors	Corbari, C.;Kazansky, P. G.;Slattery, Stephen A.;Nikogosyan, David N.
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University College Cork, Ireland Coláiste na hOllscoile Corcaigh

Erratum: "Ultraviolet poling of pure fused silica by high-intensity femtosecond radiation" [Appl. Phys. Lett. 86, 071106 (2005)]

Costantino Corbari, Peter G. Kazansky, Stephen A. Slattery, and David N. Nikogosyan

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Costantino Corbari and Peter G. Kazansky Optoelectronics Research Centre, University of Southhampton, Southhampton, United Kingdom

Stephen A. Slattery and David N. Nikogosyan Physics Department, National University of Ireland, University College Cork, Ireland

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In our paper, Eqs. (1) and (2) were typed erroneously. In order to get the correct form, they should be decreased by a factor of 2 on their right hand sides. The equations should read as follows:

$$I = \frac{\varepsilon_p}{\left(\frac{\pi}{\ln 2}\right)^{3/2} \frac{\tau w^2}{2} \left(\frac{F-S}{F}\right)^2},\tag{1}$$

$$E = \frac{\varepsilon_p N}{\frac{\pi w^2}{\ln 2} \left(\frac{F-S}{F}\right)^2}.$$
(2)

In addition, the *w* parameter used in these equations is not the beam diameter, as written in the text; it is the beam radius and should be twice less, w=0.15 cm.

These errors occurred in the rearranging of the original formulas dealing with Gaussian parameters of the beam (at the e^{-1} level), used in the processing of the experiment, to formulas using FWHM parameters. Hence, these errors do not affect any result presented in this letter.